ABSTRACT

A bump (4, 4A) is formed on each element semi¢onductor device electrode (5) of a (3), and a thermoplastic resin sheet $\sqrt[4]{7}a$) is aligned in position with the semiconductor device. / The sheet and the semiconductor device are subjected to /hot pressing to melt the sheet, forming a thermoplastic/resin portion (7) that covers a portion other than the #nd surface (9) of each bump of the semiconductor device. The thermoplastic resin portion obtained after the hot/pressing is cut.

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